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Increased terahertz emission from monolayer graphene with field enhancement effect

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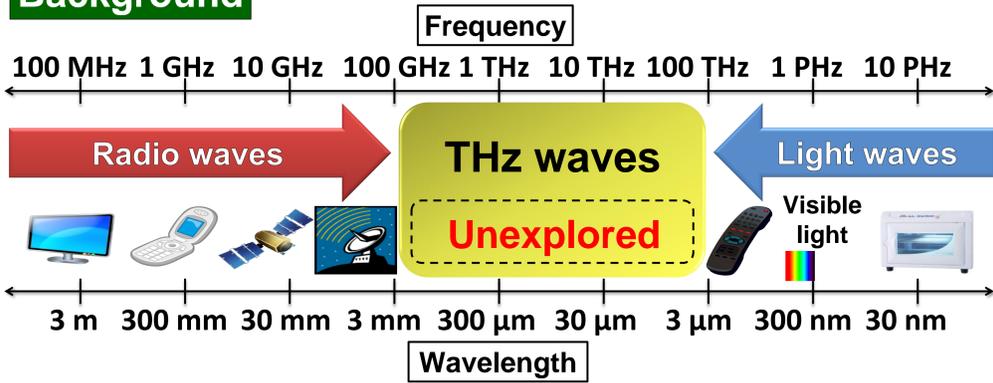
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Background



Terahertz gap

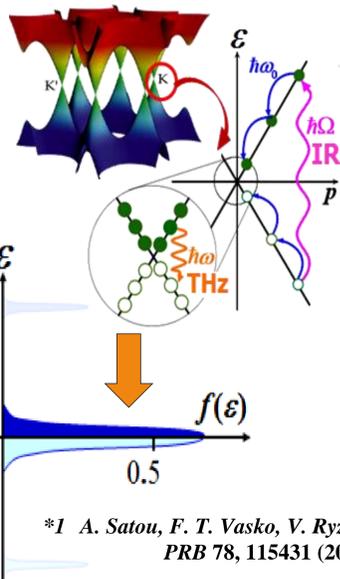
- Maximum operating frequency of electronic devices
→ Limited by **electron velocity**
- Minimum operating frequency of optical devices
→ Restricted by **thermal noise at room temperature**

We are currently developing THz devices by using a novel operating principle

Operation principle

Photo-excited graphene

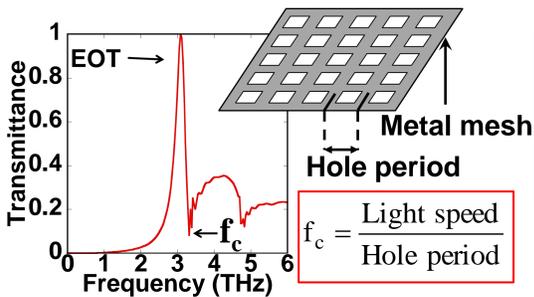
Irradiation of graphene with infrared laser
↓
Formation of population inversion from generated electron-hole pairs
↓
Emission of THz waves by recombination
Amplification of 1 – 10 THz waves



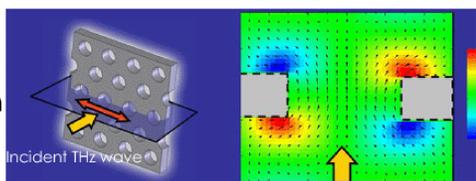
Properties of metal mesh structure

- Extraordinary optical transmission (EOT)
- Field enhancement effect caused by spoof surface plasmon polaritons (SPPs)

Transmission characteristics of metal mesh structure



Field enhancement effect due to SPPs^{*2}



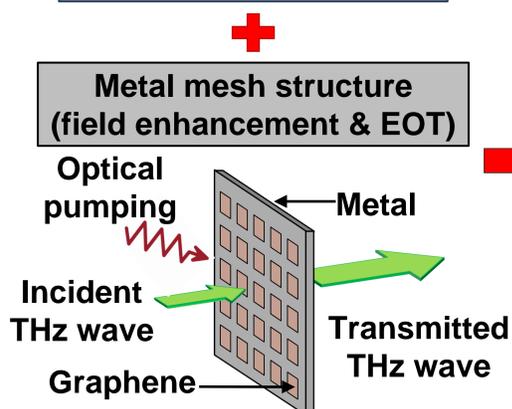
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Objective

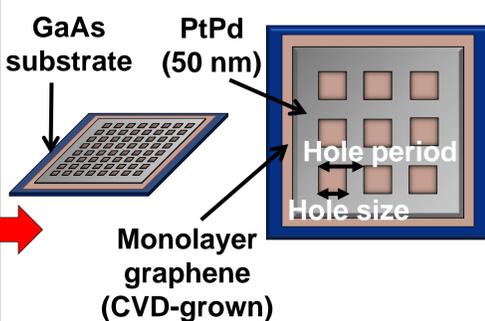
Improving our original THz amplifier to increase THz emission

Concept of THz amplifier

Graphene (THz wave gain medium) + Metal mesh structure (field enhancement & EOT)

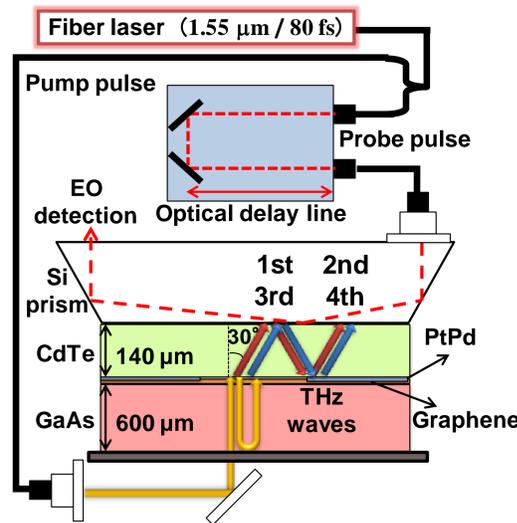


Construction of THz amplifier (GaAs + Metal + Graphene)



	Hole period	Hole size
New	20 μm	10 μm
Original	60 μm	30 μm

Measurement system

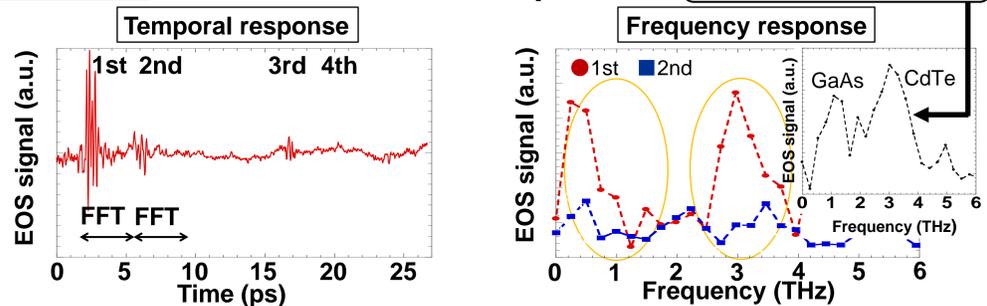


Reflective Electro-Optic Sampling

- Pump pulse
- Photoexciting the sample and CdTe crystal
- Generating THz waves in GaAs substrate and CdTe crystal by optical rectification
- Probe pulse
- Sensing electric field by electro-optic crystal (refractive index change due to electric field)

Results

GaAs + Graphene

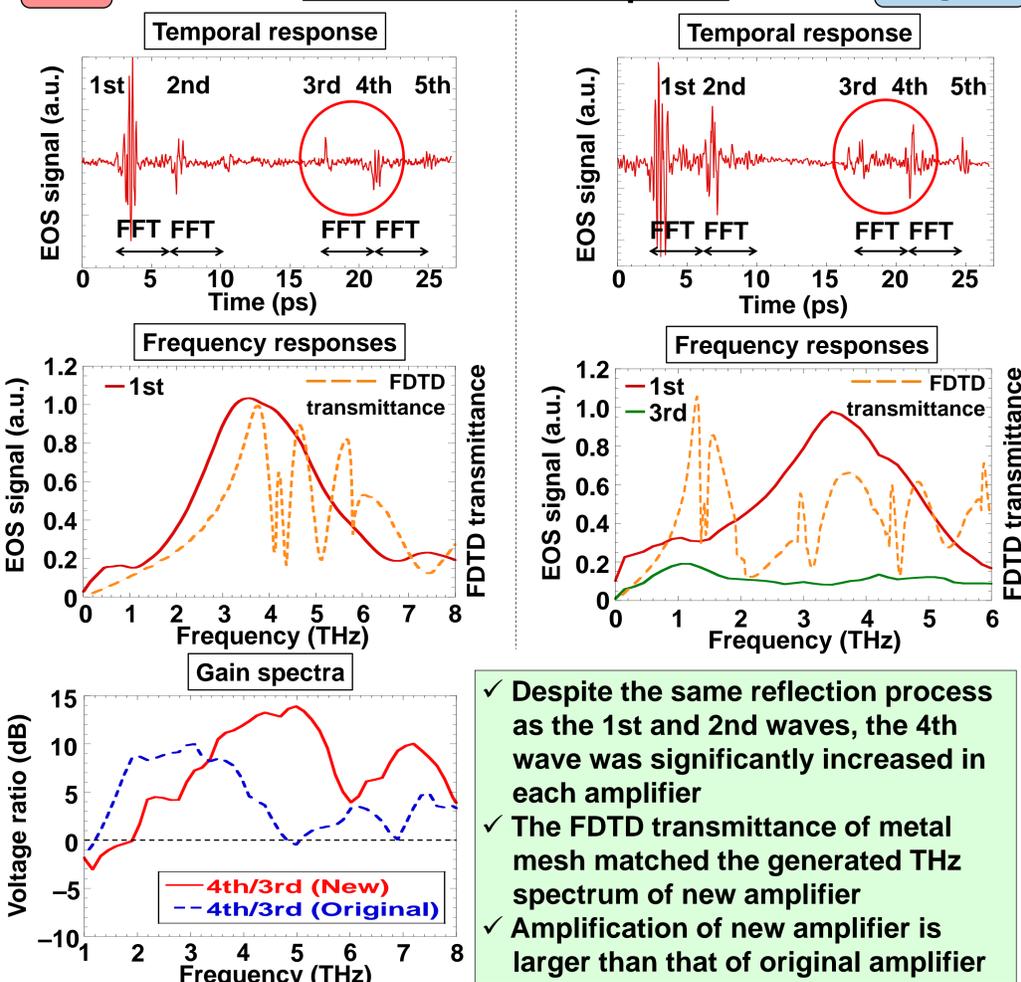


- 1st wave was similar to THz waves generated in GaAs and CdTe crystals
- 3rd and 4th waves were hardly observed
- Amplification was not achieved

New

GaAs + Metal + Graphene

Original



- Despite the same reflection process as the 1st and 2nd waves, the 4th wave was significantly increased in each amplifier
- The FDTD transmittance of metal mesh matched the generated THz spectrum of new amplifier
- Amplification of new amplifier is larger than that of original amplifier

These observations suggest

- The presence of population inversion in graphene
- Field enhancement due to SPPs (buildup time: several picosec)
- Bragg radiation

Conclusion

- Significantly enhanced THz emission from new amplifier compared to original one
- The increased voltage ratio at 3 – 6 THz was caused by the adjustment of the resonance frequency of the metal mesh to the population inversion frequency
- The combined effect of population inversion in graphene and field enhancement enables the amplification of THz waves